

INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)			Complete if Known		Date Submitted: June 29, 2009
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			First Named Inventor		F. Venema
			Art Unit		1634
			Examiner Name		Amanda M. Shaw
Sheet	B1	of	B1	Attorney Docket Number	9310-150

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code (if known)			
		US-			
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FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
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NON PATENT LITERATURE DOCUMENTS				
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	T	
	1.	HUANG and LI. "Characterization of the 5' to 3' Nuclease Activity of <i>Thermus aquaticus</i> DNA Polymerase on Fluorogenic Double-Stranded Probes" <i>Molecular and Cellular Probes</i> 23 :188-194 (2009)		
	2.	KAISER et al. "A Comparison of Eubacterial and Archaeal Structure-Specific 5'-Exonucleases" <i>The Journal of Biological Chemistry</i> 274 (30):21387-21394 (1994)		
	3.	LYAMICHEV et al. "Structure-Specific Endonucleolytic Cleavage of Nucleic Acids by Eubacterial DNA Polymerases" <i>Science</i> 260 :778-783 (1993)		

Examiner Signature		Date Considered	
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.